

FW: WOA II Second Draft

DOALOS <doalos@un.org>

Fri 9/4/2020 12:11 PM

To: Dmitry Gonchar <gonchar@un.org>; Marco Boccia <marco.boccia@un.org>; Lika Doehl Diouf <lika.diouf@un.org>; Henock Legesse Workie <legesseh@un.org>; Bingzhuo Li <bingzhuo.li@un.org>; Elena Temnova <temnova@un.org>

From: Nathaniel KHNG (MFA)

Sent: Friday, September 4, 2020 12:11:23 PM (UTC-05:00) Eastern Time (US & Canada)

To: DOALOS; Elena Temnova; Henock Legesse Workie

Cc: Ee Vun SNG (MFA); Kathleen HO (MFA)

Subject: WOA II Second Draft

Message Classification: *Confidential*

Dear Secretariat of the Regular Process,

We refer to your email dated 17 August 2020. We thank the Co-Chairs of the Ad Hoc Working Group of the Whole on the Regular Process for inviting comments on the second draft of the Second World Ocean Assessment.

2 Singapore has one comment, as set out in the table below, in relation to Chapter 11 (Changes in Liquid and Atmospheric Inputs to the Marine Environment from Land (including through Groundwater), Ships and Offshore Installations).

Reference	Excerpt from Second Draft	Comment
<u>Page 569</u> <u>7.3 Description of the environmental changes (between 2010 and 2020).</u>	“The adverse effects of air pollution caused by shipping are an issue of interest to the International Maritime Organization (IMO) which, on the basis of Annex IV VI of the International Convention for the Prevention of Pollution from Ships (MARPOL Convention), endeavours to reduce emissions through international agreements.”	Singapore proposes the amendment that is tracked in blue. Annex VI of MARPOL covers the prevention of air pollution from ships, while Annex IV is on the prevention of pollution by sewage from ships.

3 We would be grateful if our comment can be conveyed to the Group of Experts.

4 Thank you.

Your sincerely,

Nathaniel Khng
Counsellor (Legal)

Nathaniel Khng | Counsellor (Legal)

Permanent Mission of Singapore to the United Nations | New York

T +1 212 826 0840 | F +1 212 826 2964 | Mobile +1 917 808 6644

-----Forwarded by singapore/UNPM/UNO on 08/17/2020 01:01PM -----

From: legesseh@unitednations.mail.onmicrosoft.com

Date: 08/17/2020 11:36AM

Cc: gonchar@unitednations.mail.onmicrosoft.com, marco.boccia@unitednations.mail.onmicrosoft.com, bingzhuo.li@unitednations.mail.onmicrosoft.com, lika.diouf@unitednations.mail.onmicrosoft.com, temnova@unitednations.mail.onmicrosoft.com

Subject: Second draft of the second world ocean assessment (WOA II) - PMs/OMs3

(See attached file: WOA II - review by States - Letter from Co-Chairs_second draft WOA II.pdf)

Attention: All Permanent and Observer Missions to the United Nations

Further to the communication circulated on 27 April 2020 inviting United Nations Member States to provide written comments on the first draft of the second world ocean assessment (WOA II), please find attached a letter from the Co-Chairs of the Ad Hoc Working Group of the Whole on the Regular Process for Global Reporting and Assessment of the State of the Marine Environment, including Socioeconomic Aspects (Regular Process), inviting Member States to review the second draft of WOA II and the responses to their comments on the first draft of WOA II and raise any questions they may have with the Group of Experts.

To allow sufficient time for the Group of Experts to reflect, respond and/or make changes to the draft, as necessary, such questions, if any, should be communicated to the secretariat of the Regular

Process (doalos@un.org; temnova@un.org; legesseh@un.org) by the Permanent Mission of the State to the United Nations or by its designated National Focal Point for the Regular Process as soon as possible but no later than midnight (New York time) on 4 September 2020. Delegations are kindly requested to put "WOA II second draft" in the subject line.

The second draft of WOA II, the responses agreed by the Group of Experts to comments from States, as well as all comments received from States are available at: <https://www.un.org/regularprocess/WOA-II-review-by-states/draft-assessment>.

Sincerely,

DOALOS - Secretariat of the Regular Process